Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S5	2	("2001144217").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/25 17:19
S6	8	("1198003").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/25 17:25
S7	2	("20020008320").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/25 15:28
S8	430	(438/110).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/30 11:41
S9	230	S8 and (resin polymi\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/25 17:41
S10	3	("6707153").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/25 17:25
S11	13	("5470787" "5767010" "5886415" "6097087" "6287893" "6313532" "6326701" "6333565" "6348730" "6373131" "6380620" "6388335" "6389689").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/08/25 17:25
S12	313	S8 and (resin polymi\$3 epoxy (silicone adj denatured) benzocyclobutene precursor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/25 18:27

S13	78	S8 and (csp (chip near2 scale near2 size near2 package))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 09:08
S14	236	S8 and (resin polymi\$3 (silicone adj denatured) benzocyclobutene precursor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 09:08
S15	11007	csp (chip near2 scale near2 size near2 package)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 09:08
S16	4383	S15 and (resin polymi\$3 (silicone adj denatured) benzocyclobutene precursor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 09:17
S17	1005	S16 and (recess groove trench)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/30 11:52
S18	25	S17 and (interconnect\$3 near3 line)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 09:34
S19	0	("2004/0192024").URPN.	USPAT	OR	ON	2005/08/29 09:17
S20	963	(438/113).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/29 09:17
S21	418	S20 and (resin polymi\$3 (silicone adj denatured) benzocyclobutene precursor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/30 11:52

S22	171	S21 and (recess groove trench)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 09:18
S23	363	S17 and (interconnect\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 09:35
S24	216	S23 and (integrat\$3 near3 circuit)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/29 10:49
S25	225	(438/114).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/29 10:50
S26	2	("6333565").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/29 14:16
S27	2	("20020008320").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/29 14:16
S28	2	("20020005568").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/29 17:52
S29	430	(438/110).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/30 11:41

S30	14	S29 and opaque	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/30 11:45
S31	49	S29 and photolitho\$6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/30 11:51
S32	2556	(438/612).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/30 11:51
S33	603	S32 and (resin polymi\$3 (silicone adj denatured) benzocyclobutene precursor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ÖR	ON	2005/08/30 12:42
S34	151	S33 and (recess groove trench)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/30 12:43
S35	2	("2001144217").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/30 12:42
S36	1130	(438/618).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/30 12:42
S37	235	S36 and (resin polymi\$3 (silicone adj denatured) benzocyclobutene precursor)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/30 12:42

S38	127	S37 and (recess groove trench)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB	OR	ON	2005/08/30 12:43	
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